

## USAGE POLICY



- ❑ **Ion Oxide Mask Etchant ME-10** is used for etching the ion oxide from the respective areas of a developed mask plate.
- ❑ The chemical etchant will be placed in the Micro1 Chemistry room in the first rack.
- ❑ There will be dedicated petridishes in different sizes available for mask plate etching.
- ❑ Etching of mask plate can be done by immersing the mask plate in the etchant and washing it with acetone and IPA in the general purpose wet bench.
- ❑ The blower can be switched on to avoid the fumes entering outside the bench.
- ❑ Used chemicals can be disposed in the respective used bottles placed in the chemistry room last rack.